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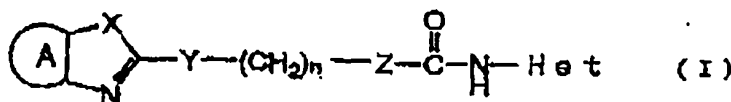
Amendments To The Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of claims:

1-8. (Cancelled)

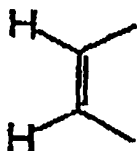
9. (Previously Amended) Compounds represented by the formula (I)



wherein



represents an optionally substituted divalent residue of benzene, cyclohexane or naphthalene, or a group:



Het represents a substituted pyridyl group;

X represents an oxygen atom;

Y represents $\text{---NR}_4\text{---}$, an oxygen atom, a sulfur atom, a sulfoxide or a sulfone;

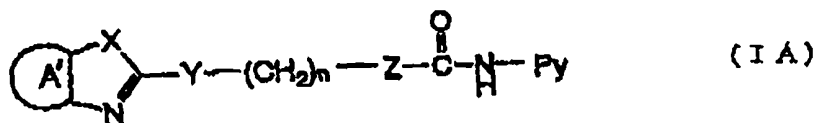
Z represents a single bond;

R_4 represents a hydrogen atom, a lower alkyl group, an aryl group or an optionally substituted silyl lower alkyl group; and

n is an integer of from 2 to 15, or salts or solvates thereof.

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10. (Previously Amended) The compounds according to claim 9, which are represented by the formula (IA)



wherein



represents an optionally substituted divalent residue of;

Py represents a substituted pyridyl group;

X represents an oxygen atom;

Y represents -NR₄-, an oxygen atom, a sulfur atom, a sulfoxide or a sulfone;

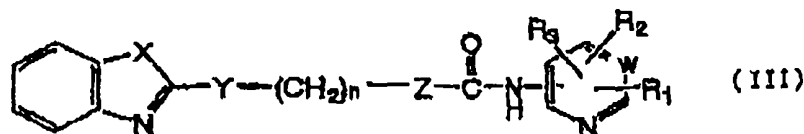
Z represents a single bond;

R₄ represents a hydrogen atom, a lower alkyl group, an aryl group or an optionally substituted silyl lower alkyl group; and

n is an integer of from 2 to 15;

or salts or solvates thereof.

11. (Previously Amended) The compounds according to claim 9, which are represented by the formula (III)



wherein, W represents =CH-;

X represents an oxygen atom;

Y represents -NR₄-, an oxygen atom, a sulfur atom, a sulfoxide or a sulfone;

Z represents a single bond;

R₁, R₂, and R₃ are the same or different, and each represents a hydrogen atom, a lower alkyl group, a lower alkoxy group, a halogen atom, a hydroxyl group, a phosphate group, a

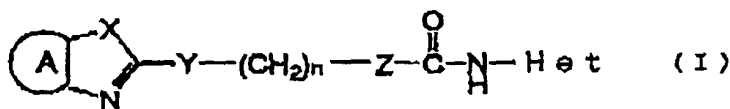
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sulfonamide group, a lower alkylthio group or an optionally substituted amino group, or two of R_1 , R_2 , and R_3 , together form an alkylenedioxide group, provided that R_1 , R_2 and R_3 are not hydrogen at the same time;

R_4 represents a hydrogen atom, a lower alkyl group, an aryl group or an optionally substituted silyl lower alkyl group; and

n is an integer of from 2 to 15, or salts or solvates thereof.

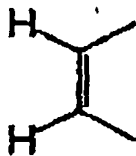
12. (Previously Amended) A pharmaceutical composition comprising a pharmaceutically acceptable carrier and at least one compound selected from the compounds represented by the formula (I)



wherein



represents an optionally substituted divalent residue of benzene, cyclohexane or naphthalene, or a group:



Het represents a substituted pyridyl group;

X represents an oxygen atom;

Y represents -NR-, an oxygen atom, a sulfur atom, a sulfoxide or a sulfone;

Z represents a single bond;

R_4 represents a hydrogen atom, a lower alkyl group, an aryl group or an optionally substituted silyl lower alkyl group; and

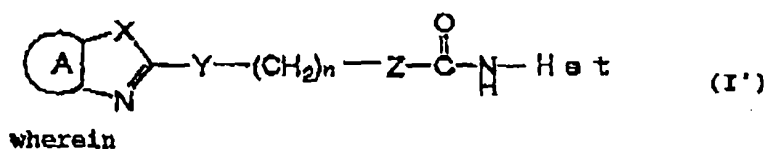
n is an integer of from 2 to 15, or salts or solvates thereof.

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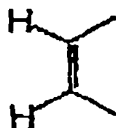
13. (Cancelled)

14. (Presently Amended) The pharmaceutical composition according to claim 12 or 13, which is a remedy or a medication for preventing hyperlipemia, arteriosclerosis, cerebrovascular accidents, ischemic heart disease, ischemic intestinal disease or aortic aneurysm.

15. (Previously Amended) A method for treating hyperlipemia, arteriosclerosis, cerebrovascular accidents, ischemic heart disease, ischemic intestinal disease or aortic aneurysm by administering to a patient in need of such treatment a compound of the formula (I')



represents an optionally substituted divalent residue of benzene, cyclohexane or naphthalene, or a group:



Het represents substituted or unsubstituted pyridyl group;

X represents an oxygen atom;

Y represents -NR₄-, an oxygen atom, a sulfur atom, a sulfoxide or a sulfone;

Z represents a single bond;

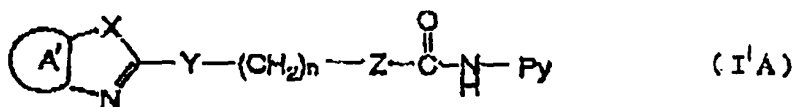
R₄ represents a hydrogen atom, a lower alkyl group, an aryl group or an optionally substituted silyl lower alkyl group; and

n is an integer of from 1 to 15;

or salts or solvates thereof.

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16. (Previously Amended) The method of claim 15 wherein a compound of formula (I'A) is administered



wherein



represents an optionally substituted divalent residue of benzene;

Py represents an optionally substituted pyridyl group;

X represents an oxygen atom;

Y represents -NR₄-, an oxygen atom, a sulfur atom, a sulfoxide or a sulfone;

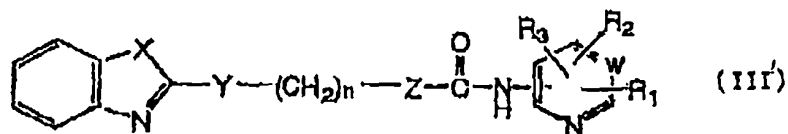
Z represents a single bond;

R₄ represents a hydrogen atom, a lower alkyl group, an aryl group or an optionally substituted silyl lower alkyl group;

n is an integer of from 1 to 15,

or salts or solvates thereof.

17. (Previously Amended) The method of claim 15 wherein a compound of formula (III') is administered



wherein, W represents =CH-,

X represents an oxygen atom;

Y represents -NR₄-, an oxygen atom, a sulfur atom, a sulfoxide or a sulfone;

Z represents a single bond;

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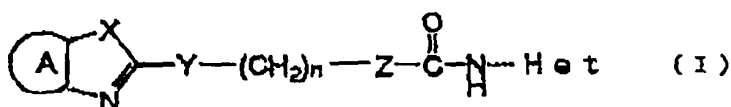
R_1 , R_2 , and R_3 are the same or different, and each represents a hydrogen atom, a lower alkyl group, a lower alkoxy group, a halogen atom, a hydroxyl group, a phosphate group, a sulfonamide group, a lower alkylthio group or an optionally substituted amino group, or two of R_1 , R_2 , and R_3 , together form an alkylenedioxide group;

R_4 represents a hydrogen atom, a lower alkyl group, an aryl group or an optionally substituted silyl lower alkyl group; and

n is an integer of from 1 to 15;

or salts or solvates thereof.

18. (Previously Amended) A method claim 15 wherein a compound represented by formula (I) is administered,



wherein



represents an optionally substituted divalent residue of benzene;

Het represents a substituted or unsubstituted pyridyl group;

X is an oxygen atom;

Y is a sulfur atom;

Z is a single bond;

n is 1;

or salts or solvates thereof.